# Active pixel sensors in ams H18/H35 HV-CMOS technology for the ATLAS HL-LHC upgrade

10th International "Hiroshima" Symposium Xi'an, China







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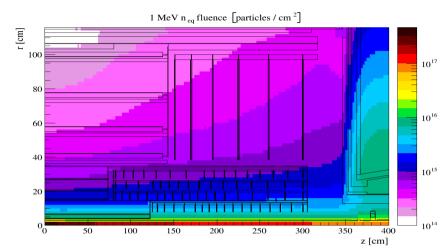
On behalf of the ATLAS HVCMOS R&D Collaboration

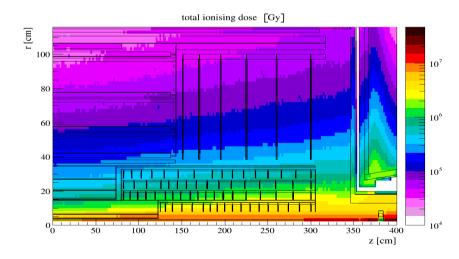


# LHC Upgrade



- LHC upgrade to higher luminosities planned for 202x
  - Integrated luminosity: 300 fb<sup>-1</sup> → 3000 fb<sup>-1</sup>
- Hybrid detectors proven to be rad-hard enough
- Main drawback: Price
  - Bump bonding expensive due to special processes
  - Sensor processes non-standard + on small wafers
  - ITk requires ~100-200m² of silicon → price matters







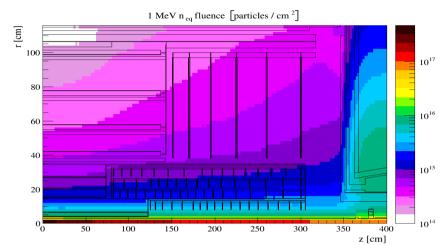
# LHC Upgrade

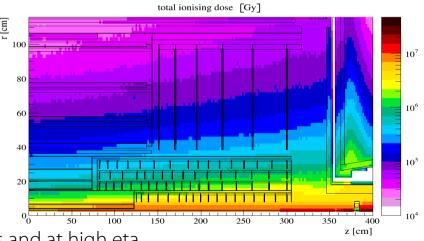


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- ... and interconnection technologies
- Commercially available by variety of foundries
  - Large volumes, multiple vendors
- 8" to 12" wafers
  - Low cost per area, wafer thinning quite standard
- usually p-type Cz silicon
  - Thin active layer, helpful to disentangle tracks in boosted jets and at high eta
    - Requires low capacitance → small pixels





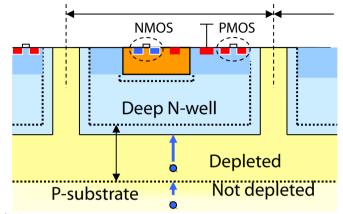


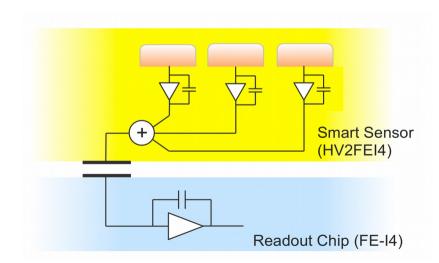
### HV-CMOS sensors in ams technology



Austria Micro Systems offers HV-CMOS processes with 180nm and 350nm feature size

- Several substrate resistivities O(10 1000)Ωcm
  → N<sub>eff</sub> > 10<sup>11</sup>...10<sup>14</sup>/cm<sup>3</sup>
- Collecting electrode and HV isolation → Deep N-Well
- Biasing of substrate to ~60-100V(H18) ~150V (H35)
- Depletion depth theoretically in the order of 10 100μm
  → Drift signal ~500...O(1000)e-
- On-sensor amplification possible and necessary for good S/N
  - Key: small pixel sizes → low capacitance → low noise
- Additional circuits, e.g. discriminator
  - Adjustable high output signal
  - Capacitive coupling (CCPDs)
  - Sub-pixel encoding (small pixels)
- Hybridization by gluing using flip chip machines
  - Glue thicknesses of several µm reached
  - Below 1 μm precise alignment

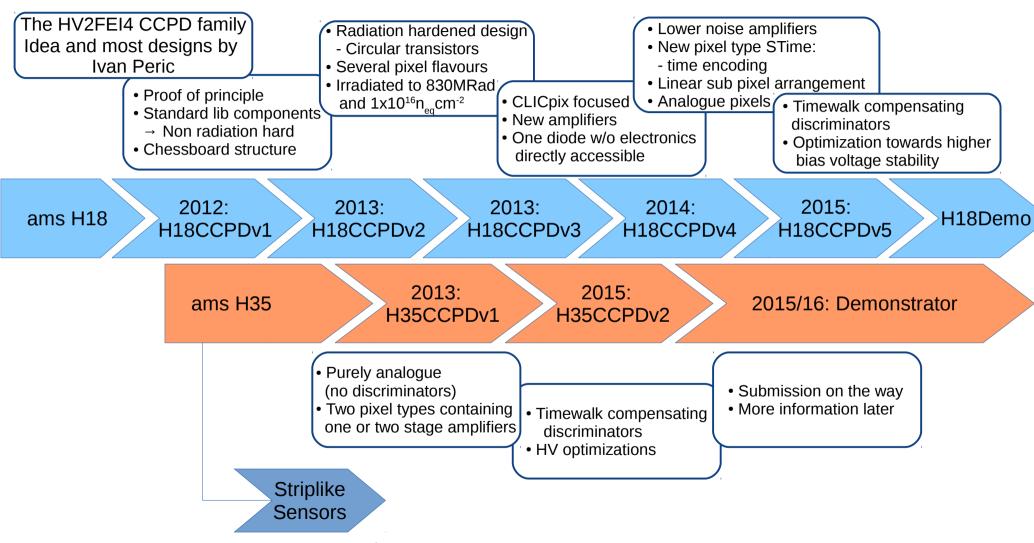






### A short story of ams CCPDs for ATLAS





→ see Zhijun Liang's poster



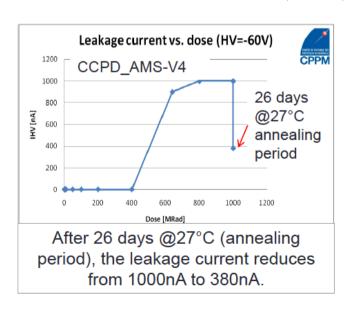
# Irradiation of H18CCPDv4 samples

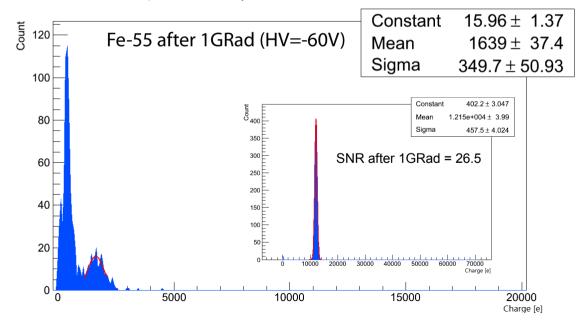


X-Ray irradiation up to 1000MRad (158.4MRad/day): stand alone CCPD V4, powered



- Increase of leakage current after 400 MRad
  - Drops to 380 nA after 26 days of annealing at room temperature
    - → High temperature annealing not necessary
- Amplifier with linear and circular feed back transistor investigated
  - Linear FB transistor shows noise after 100MRad
  - Circular FB transistor remains quiet up to 1GRad → Fe-55 peak clearly visible







### Irradiation of H18CCPDv4 samples



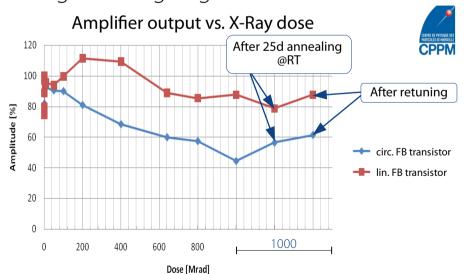
X-Ray irradiation up to 1000MRad: stand alone CCPD V4, powered

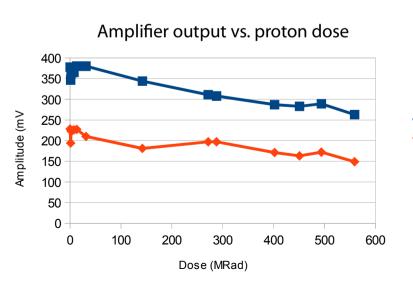


- Amplifier output signal recovered by annealing at room temperature and retuning
  - Relative amplitude of linear FB transistor: 88%, but noisy
  - Relative amplitude of cicrular FB transistor: 62%

Proton irradiation up to 560MRad:stand alone CCPD V4, powered

- No annealing or retuning performed
  - Relative amplitude of linear FB transistor: 75%, but noisy
  - Relative amplitude of cicrular FB transistor: 63%
- Investigation ongoing







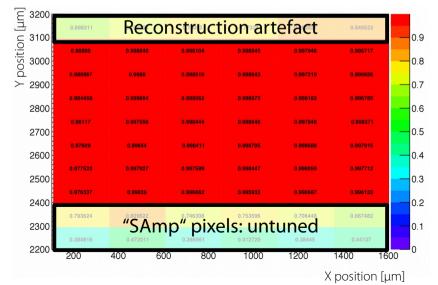


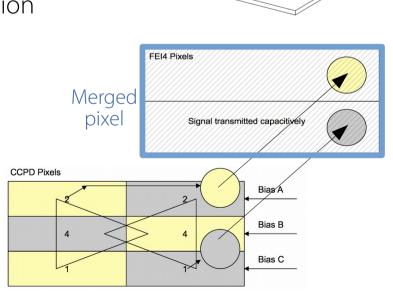
# Testbeam results on H18CCPDv4 samples



- Multiple testbeam periods during last 1.5 years
- Performed using new FEI4 based telescope
  - Resolution at DUT ~8/12um for typical telescope configuration
- Two H18CCPDv4 samples tested
  - 402: unirradiated and 404: 1x10<sup>15</sup>n<sub>eq</sub>cm<sup>-2</sup>
  - Subpixel encoding not tested → FE-I4 pixel pairs merged

• High efficiency of 99.7% before and 96.2% after irradiation





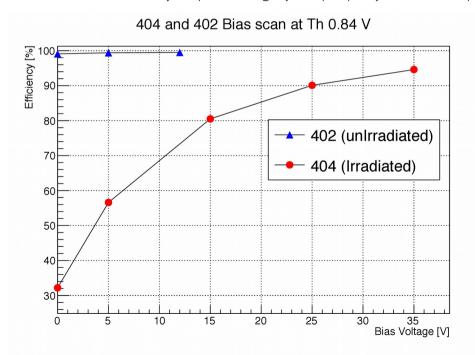
Telescope Planes

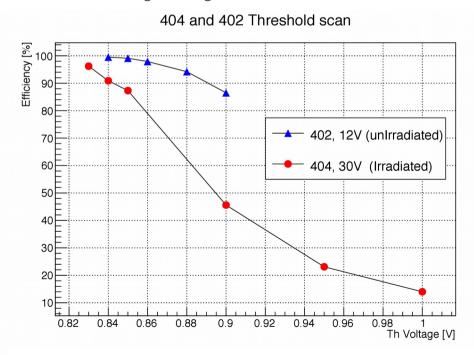


### Bias and threshold Scans



- Bias scan from 0V to breakdown voltage performed
  - Diffusion contributes significantly to signal in unirradiated case
  - Early breakdown prevented optimal performance (especially in case of irradiated sample)
  - H18v4 samples can be biased up to ~95V → New data expected this year
- Threshold scan from close to the noise edge to up to several thousand electrons performed
  - Detection efficiency depends highly on properly tuned sample (if not biased with high voltages)



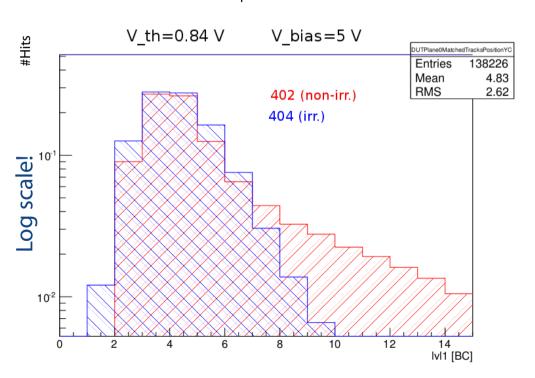


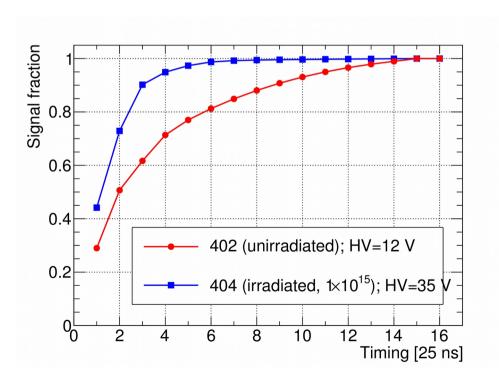


# Timing comparison



- Output signal shows broad timing distribution of several bunch crossings
- Slow signal/tail suppressed after irradiation hinting on trapping of diffusion component
  - Improvement of timing can be reached by higher bias voltages → higher drift fraction of signal
- ATLAS requires signal generation in one bunch crossing
  - → Time walk compensation in H18v5





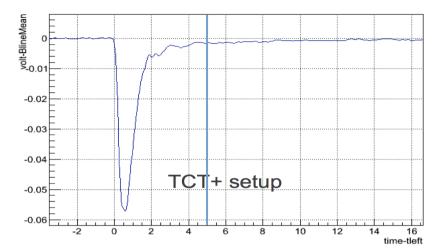


# (Edge) Transient Current Technique



TCT (Transient Current Technique): record time-resolved charge collection

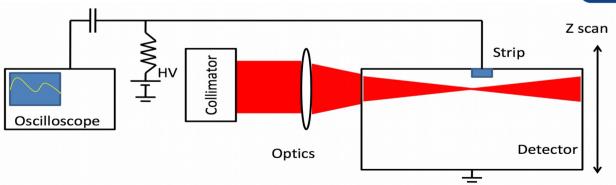
- Charges usually generated via infrared laser, shot into the bulk of sensor
  - Constant charge deposition per pulse → averaging over many pulses cancels noise
- Observables: Transient current (charge movement) Integrals (collected charge)
- Fast signals (~ns) → External amplification, fast readout with scopes
- Edge TCT: shooting in through the side-wall of the sensor with a IR laser
  - Can study the charge collection at different depths → depletion?



#### Why E-TCT?

- Expected depletion depth for 10 Ohm\*cm around 10 μm → 500-600e for a MIP
- Observed: ~1500-1900 e<sup>-</sup> (~1200 e<sup>-</sup> after irradiation) from in-pixel charge-sensitive amplifiers
  - Origin of discrepancy unclear

Christian Gallrapp CERN / PH-DT-DD





### E-TCT on ams samples

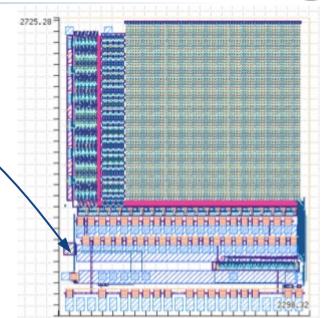


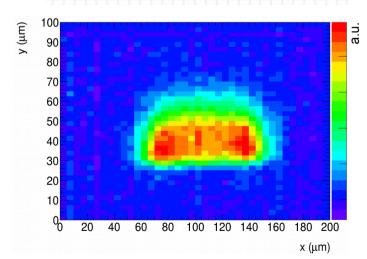
#### Measurements on H18CCPDv3 samples

- $10\Omega$ cm substrate, max. ~90V bias
- One dedicated passive 100 x 100 μm<sup>2</sup> diode accessible –
- No neigbours → possible edge effects
- Irradiation at CERN PS (Irrad 1) without biasing
  - Fluences: 2.3, 6 and 11.1x10 $^{15}$  p/cm $^2$  (1.42, 3.72 and 6.9x10 $^{15}$  n<sub>eq</sub>/cm $^2$ )
  - p-irradiated samples cooled to 0 degrees for measurement
- Irradiation at JSI Ljubljana, Slovenia
  - Fluences: 1, 7, 20x10<sup>15</sup> n<sub>eq</sub>/cm<sup>2</sup>
- Collected charge obtained as integral over 5ns

#### Measurements on H35 samples (CHESS1)

- 20Ωcm substrate, max. 120V bias
- 100 x 45 μm² diodes forming an array accessible
- Irradiation at JSI Ljubljana, Slovenia
  - Fluences: 0.2, 0.5, 1, 2, 5, 10x10<sup>15</sup> n<sub>ea</sub>/cm<sup>2</sup>
- Collected charge obtained as integral over 25ns (!)







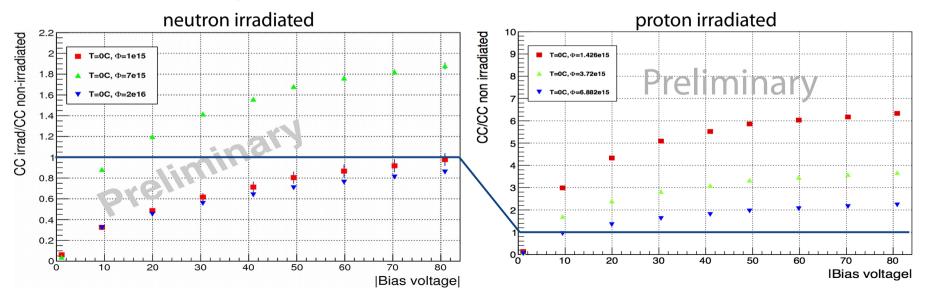
### E-TCT results of ams H18 Samples



- Relative charge collection (CC) after neutron irradiation
  - CC at 0V after  $1x10^{15}$   $n_{eq}$ /cm<sup>2</sup> near 0  $\rightarrow$  Diffusion component degraded by trapping

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- Can be recovered to 85% even after 2x10<sup>16</sup> n<sub>eq</sub>/cm<sup>2</sup>
- Collected charge doubled in case of  $7x10^{15}$   $n_{eq}$ /cm<sup>2</sup>  $\rightarrow$  Acceptor removal effect  $\rightarrow$  Deeper depletion zone
- ....and after proton irradiation
  - CC exceeds unirradiated case at below 10V
  - Largest collection after  $1.42 \times 10^{15} \, n_{eq}/cm^2$  (p irradiation) reaches relative CC of up to 6 at 80V
    - → Acceptor removal for protons much stronger than for neutrons at that fluence
  - Comparable after  $7x10^{15} n_{eq}/cm^2$ : 1.9 (n) vs. 2.2 (p) at 80V



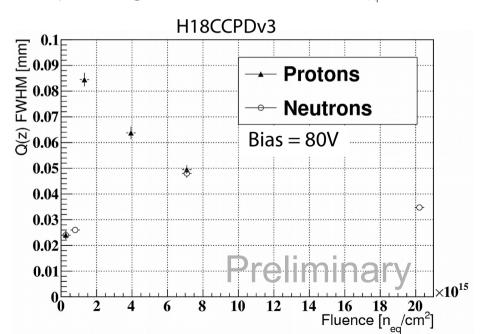


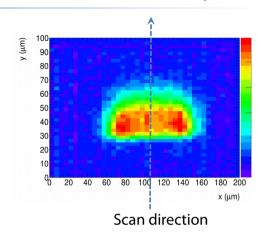
# Depletion depth on H18 and H35 samples

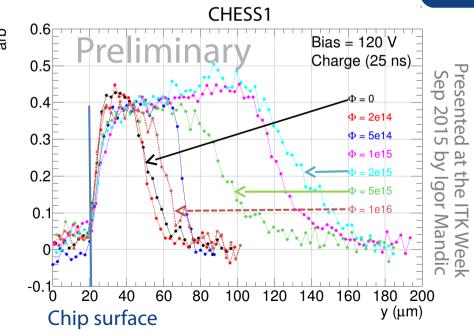


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- Depletion depths obtained as FWHM of scanning over y
- H18 and H35 samples yield comparable results
  - 1x10<sup>15</sup> n<sub>ea</sub>/cm<sup>2</sup> inconclusive: Precise knowledge of fluence crucial
- Results confirm charge collection measurements
  - Discrepancy between proton and neutron irradiation
  - Equal charge collection for  $\sim 7 \times 10^{15} \, n_{eq} / cm^2$









### The AMS H35 Demonstrator

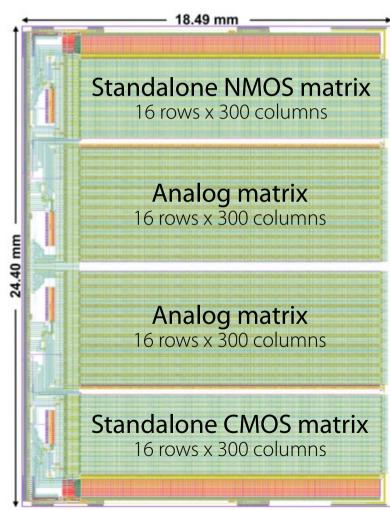
#### IFAE | KIT University of Liverpool



- Engineering run, proving feasibility of full reticle size sensors
- Built in AMS H35 350nm HV-CMOS process
- Substrate resistivities: 20, 80, 200,  $1000\Omega$ cm
- Submission on-going

#### Floorplan

- Analog pixels (only amplifiers) for FEI4 coupling
  - 3 flavours optimized for gain and/or speed
- Standalone NMOS matrix
  - Different in-pixel amplifiers and discriminators
  - Read out by FE-I4 or an FE-I3 like digital structure at periphery
- Standalone CMOS matrix
  - Different in-pixel amplifiers
  - Can be read out by FE-I4
  - CMOS discriminators at periphery and FE-I3 like digital structure at periphery



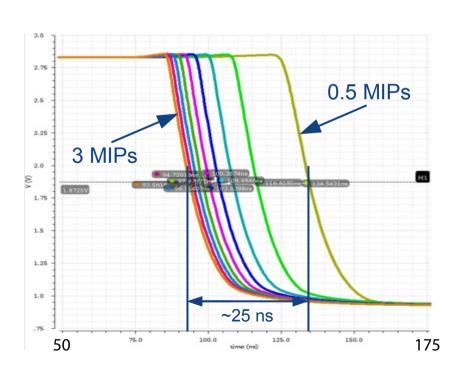


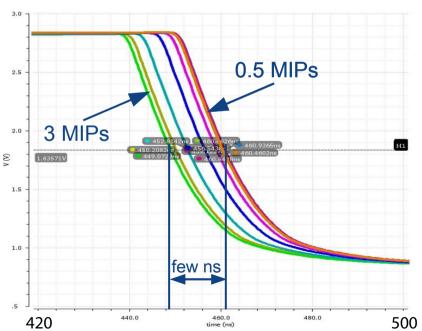
### The AMS H35 Demonstrator

#### IFAE | KIT University of Liverpool



- Timewalk has been addressed by a timewalk compensating discriminator
- Post design simulation reveals significant improvement especially for low charges
- Higher substrate resistivities will yield higher signals, further mitigating this issue
  - Possible backside implant for HV biasing → homogenious E-field through bulk









### Summary and outlook



- HV-CMOS sensors are promising sensor candidates for the upgrade of the ATLAS Inner Tracker
  - Very good detection performance and radiation hardness
  - Cost efficient (standard processes and gluing instead of bump bonding)
  - Offered by various vendors and in big volumes
- Testbeam measurements yield detection efficiencies of up to 99.7% for irradiated and 96.2% for 1x10<sup>15</sup>n<sub>ea</sub>cm<sup>-2</sup> irradiated samples under non-optimal conditions
- Deteorioration of Amplifier signals after irradiation with ionizing particles can be mitigated by room temperature annealing and retuning
- Timewalk issue has been identified and addressed by improved comparator design
- Edge TCT measurements show improved charge collection for irradiated sensors due to the acceptor removal effect
  - Up to 6 times (2 times for neutron irradiation) the initial charge collected for 1...2x1015neqcm-2
- Full size demonstrator design in H35 technology prepared
  - Production on several (high) bulk resistivities for improved SNR
  - Back side metallization by ams possible
- Mu3e tracker will be built as HV-CMOS MAPS → Implementation for ATLAS conceivable





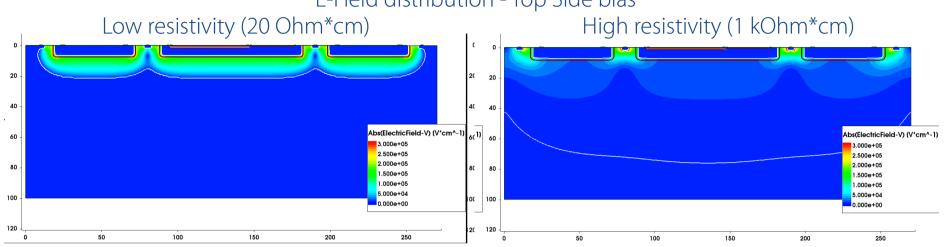
# Backup



### HV Biasing - bulk resistivity and contact position







#### E-Field Lines - High resistivity (1 kOhm\*cm)

